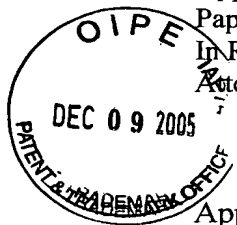


Application No. 10/783,386  
Paper Dated December 7, 2005  
In Reply to Restriction Requirement of October 7, 2005  
Attorney Docket No. 4262-031384



IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Application No. : 10/783,386 Confirmation No. 6408  
Applicants : Larry F. Rhodes et al.  
Filed : February 20, 2004  
Title : Dissolution Rate Modifiers for Photoresist Compositions  
Group Art Unit : 1752  
Examiner : Amanda C. Walke  
Customer No. : 28289

**RESPONSE TO RESTRICTION REQUIREMENT**

Mail Stop Amendment  
Commissioner for Patents  
P.O. Box 1450  
Alexandria, VA 22313-1450

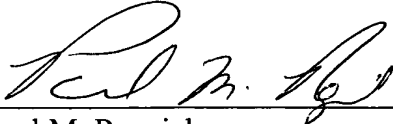
Sir:

In response to the Restriction Requirement dated October 7, 2005, Applicants elect Group I, claims 1-21, for prosecution, without traverse. Applicants elect the structure shown in Fig. 16B, a methoxy methyl ether (MOM) protected HFANB monomer, and described in paragraphs [0074] and [0084] and Synthesis Examples 15 and 16, as the representative species within this group.

An action on the merits is respectfully requested at an early date.

Respectfully submitted,

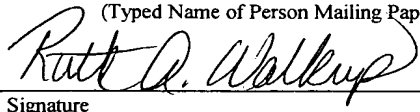
THE WEBB LAW FIRM

By 

Paul M. Reznick  
Registration No. 33,059  
Attorney for Applicants  
700 Koppers Building  
436 Seventh Avenue  
Pittsburgh, PA 15219-1845  
Telephone: (412) 471-8815  
Facsimile: (412) 471-4094  
E-mail: [webblaw@webblaw.com](mailto:webblaw@webblaw.com)

I hereby certify that this correspondence is being deposited with the United States Postal Service as first class mail in an envelope addressed to Commissioner for Patents, P.O. Box 1450, Alexandria, VA 22313-1450 on December 7, 2005.

Ruth A. Walkup  
(Typed Name of Person Mailing Paper)



Signature

12/07/2005  
Date